Acta Crystallographica Section E Structure Reports Online

ISSN 1600-5368

Jeffrey C. Bryan,^a* Anthony K. Burrell^b and Gregory J. Kubas^c

^aChemical and Analytical Sciences Division, Oak Ridge National Laboratory, Oak Ridge, TN 37831, USA, ^bInstitute of Fundamental Sciences, Massey University, Private Bag 11222, Palmerston North, New Zealand, and ^cChem-8, Los Alamos National Laboratory, Los Alamos, NM 87545, USA

Correspondence e-mail: bryanjc@ornl.gov

Key indicators

Single-crystal X-ray study T = 203 KMean $\sigma(C-C) = 0.004 \text{ Å}$ Disorder in main residue R factor = 0.032 wR factor = 0.098 Data-to-parameter ratio = 19.4

For details of how these key indicators were automatically derived from the article, see http://journals.iucr.org/e.

© 2001 International Union of Crystallography

Printed in Great Britain - all rights reserved

 $[TcCl(CS)(dppe)_2] \cdot C_6H_6$

The title compound, chlorobis[1,2-ethanediylbis(diphenylphosphine)-P,P'](thiocarbonyl-C)technetium benzene solvate, [TcCl(C₄₆H₄₂P₄)(CS)]·C₆H₆, was obtained as one of two Tc-containing products isolated from the reaction between CS₂ and the electron-deficient complex [TcCl\th>(dppe)₂], where dppe is 1,2-ethanediylbis(diphenylphosphine). The structure exhibits an unusually short Tc-C distance [1.819 (6) Å], suggesting some multiple-bond character.

Comment

Two new compounds were prepared during an examination of the reactivity of the 16-electron complex $[TcCl(dppe)_2]$, where dppe is 1,2-ethanediylbis(diphenylphosphine) (Burrell, Kubas & Bryan, 1994). Both a dithioformate complex, $[Tc-th>(S_2CH)(dppe)_2]$ (Bryan *et al.*, 2001) and a thiocarbonyl complex $[TcCl(CS)(dppe)_2]$ were formed. The latter, (I), is the topic of this paper and is the first reported example of a Tc– thiocarbonyl complex.

Ph₂



metal-organic papers

Received 13 November 2000 Accepted 4 December 2000 Online 14 December 2000

Dedicated to Warren R. Roper.



Figure 1

The molecular structure of the title compound showing 50% probability displacement ellipsoids. The benzene solvate and all H atoms have been omitted for clarity.

bond lengths typically range from 1.88 to 2.00 Å, with a mean value of 1.93 Å (Allen & Kennard, 1993). Otherwise, the title complex is structurally quite similar to the isoelectronic [ReCl(CO)(dppe)₂] (da Silva *et al.*, 1998).

Experimental

 $[TcCl(dppe)_2]$ (100 mg) was added to a benzene (50 ml) solution containing CS₂ (0.2 ml) and triphenylphosphine (50 mg). This mixture was heated to reflux for 2 min and then allowed to cool. Hexane was added to the solution and then the mixture was allowed to stand. Over time, a mixture of orange and yellow crystals were deposited. The yellow crystals proved to be $[TcCl(CS)(dppe)_2] \cdot C_6H_6$.

Z = 1

Crystal data

$$\begin{split} & [\text{TcCl}(\text{C}_{46}\text{H}_{42}\text{P}_{4})(\text{CS})] \cdot \text{C}_{6}\text{H}_{6} \\ & M_{r} = 1053.3 \\ & \text{Triclinic}, P\overline{1} \\ & a = 10.3872 \ (10) \text{ Å} \\ & b = 10.5518 \ (9) \text{ Å} \\ & c = 12.8953 \ (11) \text{ Å} \\ & \alpha = 67.185 \ (6)^{\circ} \\ & \beta = 72.620 \ (9)^{\circ} \\ & \gamma \approx 8.849 \ (8)^{\circ} \\ & V = 1243.3 \ (2) \text{ Å}^{3} \end{split}$$

Data collection

Siemens P4 diffractometer ω scans Absorption correction: ψ scan (*SHELXTL-Plus*; Siemens, 1990) $T_{min} = 0.732$, $T_{max} = 0.897$ 7126 measured reflections 6069 independent reflections 5372 reflections with $I > 2\sigma(I)$ $\begin{array}{l} D_x = 1.41 \ \mathrm{Mg \ m^{-3}} \\ \mathrm{Mo} \ K\alpha \ \mathrm{radiation} \\ \mathrm{Cell \ parameters \ from \ 25} \\ \mathrm{reflections} \\ \theta = 6.7 - 26.0^{\circ} \\ \mu = 0.55 \ \mathrm{mm^{-1}} \\ T = 203 \ \mathrm{K} \\ \mathrm{Plate, \ yellow} \\ \mathrm{0.58 \ \times \ 0.51 \ \times \ 0.15 \ mm} \end{array}$

D 0.012
$K_{int} = 0.012$
$\theta_{\rm max} = 29.0^{\circ}$
$h = -1 \rightarrow 13$
$k = -13 \rightarrow 13$
$l = -17 \rightarrow 17$
3 standard reflections
every 97 reflections
intensity decay: 1.24%

Refinement

$w = 1/[\sigma^2(F_o^2) + (0.0560P)^2]$
+ 0.0349P]
where $P = (F_o^2 + 2F_c^2)/3$
$(\Delta/\sigma)_{\rm max} = 0.001$
$\Delta \rho_{\rm max} = 0.74 \ {\rm e} \ {\rm \AA}^{-3}$
$\Delta \rho_{\rm min} = -0.92 \text{ e } \text{\AA}^{-3}$

 Table 1

 Selected geometric parameters (Å, °).

Tc-Cl	2.538 (2)	Tc-C1	1.819 (6)
Tc-P1	2.4091 (6)	S-C1	1.468 (7)
Tc-P2	2.4355 (6)		
Cl-Tc-P1	95.43 (3)	P1-Tc-C1	96.3 (2)
Cl-Tc-P2	98.00 (3)	P2-Tc-C1	96.3 (2)
Cl-Tc-C1 ⁱ	178.0 (2)	Tc-C1-S	178.1 (3)
P1-Tc-P2	80.67 (2)	P1-C11-C16	123.7 (2)

Symmetry code: (i) 1 - x, 1 - y, 1 - z.

All H atoms were placed in calculated positions, refined using a riding model, and given an isotropic displacement parameters equal to 1.2 times the equivalent isotropic displacement parameter of the atom to which they were attached.

Data collection: *XSCANS* (Siemens, 1994); cell refinement: *XSCANS*; data reduction: *XSCANS*; program(s) used to solve structure: *SHELXS*86 (Sheldrick, 1985); program(s) used to refine structure: *SHELXL*97 (Sheldrick, 1997); molecular graphics: *ORTEP*-3 (Farrugia, 1997); software used to prepare material for publication: *PLATON* (Spek, 2000).

This work was supported by the Laboratory Directed Research and Development program and the US Department of Energy, Office of Science, Office of Basic Energy Sciences.

References

Allen, F. H. & Kennard, O. (1993). Chem. Des. Autom. News, 8, 1, 31-37.

- Bryan, J. C., Burrell, A. K. & Kubas, G. J. (2001). Acta Cryst. E57, m1-2.
- Burrell, A. K., Kubas, G. J. & Bryan, J. C. (1994). J. Am. Chem. Soc. 116, 1575– 1576.
- Burrell, A. K., Bryan, J. C. & Kubas, G. J. (1994). Organometallics, 13, 1067– 1069.
- Silva, M. F. C. G. da, Ferreira, C. M. P., da Silva, J. J. R. F. & Pombeiro, R. J. L. (1998). J. Chem. Soc. Dalton Trans. pp. 4139–4146.
- Farrugia, L. J. (1997). J. Appl. Cryst. 30, 565.
- Sheldrick, G. M. (1985). SHELXS86. In Crystallographic Computing 3, edited by G. M. Sheldrick, C. Krüger & R. Goddard, pp. 175–189. Oxford University Press.

Sheldrick, G. M. (1997). SHELXL97. University of Göttingen, Germany.

- Siemens (1990). SHELXTL-Plus. Version 4.21. Siemens Analytical X-ray Instruments Inc., Madison, Wisconsin, USA.
- Siemens (1994). XSCANS. Version 2.10b. Siemens Analytical X-ray Instruments Inc., Madison, Wisconsin, USA.
- Spek, A. L. (2000). PLATON. Utrecht University, The Netherlands.